| | Application No. | Applicant(s) | |
|--|---|---|---------------------------|
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| Notice of Allowability | 10/657,251 Examiner | NOMURA ET AL. | |
| • | | | |
| | Alan A. Mathews | 2851 | |
| The MAILING DATE of this communication appe All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RI of the Office or upon petition by the applicant. See 37 CFR 1.313 | (OR REMAINS) CLOSED in this app or other appropriate communication GHTS. This application is subject to | olication. If not include will be mailed in due | ed course. THIS |
| 1. \boxtimes This communication is responsive to <u>communication filed 3</u> | <u>3-16-05</u> . | | |
| 2. ☑ The allowed claim(s) is/are <u>24-44</u> . | | | |
| 3. \boxtimes The drawings filed on <u>06 June 2001</u> are accepted by the Ex | xaminer. | | |
| 4. Acknowledgment is made of a claim for foreign priority unall a) All b) Some* c) None of the: 1. Certified copies of the priority documents have 2. Certified copies of the priority documents have 3. Copies of the certified copies of the priority documents have International Bureau (PCT Rule 17.2(a)). * Certified copies not received: | been received. been received in Application No. <u>09</u> | · · · · · · · · · · · · · · · · · · · | tion from the |
| Applicant has THREE MONTHS FROM THE "MAILING DATE" on noted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE. | ENT of this application. | | * |
| A SUBSTITUTE OATH OR DECLARATION must be submi INFORMAL PATENT APPLICATION (PTO-152) which give | | | OTICE OF |
| 6. CORRECTED DRAWINGS (as "replacement sheets") mus | | | |
| (a) ☐ including changes required by the Notice of Draftspers | - · | 948) attached | |
| 1) ☐ hereto or 2) ☐ to Paper No./Mail Date (b) ☐ including changes required by the attached Examiner's | | office action of | |
| Paper No./Mail Date | Amendment / Comment of in the C | ince action of | |
| Identifying indicia such as the application number (see 37 CFR 1. each sheet. Replacement sheet(s) should be labeled as such in the | | | back) of |
| 7. DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT for the second secon | | | Note the |
| Attachment(s) | _ | | |
| 1. Notice of References Cited (PTO-892) | 5. Notice of Informal Pa | | D-152) |
| 2. Notice of Draftperson's Patent Drawing Review (PTO-948) | 6. ☐ Interview Summary Paper No./Mail Dat | e | |
| Information Disclosure Statements (PTO-1449 or PTO/SB/0- Paper No./Mail Date | 8), 7. ⊠ Examiner's Amenda | Comment // Comment | |
| 4. Examiner's Comment Regarding Requirement for Deposit | 8. Examiner's Stateme | nt of Reasons for Allo | wance |
| of Biological Material | 9. | Elan Q | Mathen |
| | | Alan A. Mathew Primary Examin | /s |

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TERMINAL DISCLAIMER

1. The TERMINAL DISCLAIMER filed March 16, 2005, has been approved and has been entered.

Priority

2. The Examiner has checked the IFW file of the parent application (S.N. 09/923,443) and has found the certified copy of the foreign priority papers, which were filed August 8, 2001.

REASONS FOR ALLOWANCE

3. The following is an examiner's statement of reasons for allowance:

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

The prior art of record does not disclose or suggest at least one diffraction grating pattern being divided into eight regions, each of the regions includes a diffraction grating, and an image of the at least one diffraction grating pattern being projected onto a test substrate Art Unit: 2851

or an image detector by the projection-type exposure apparatus in combination with all the other elements recited in independent claim 24.

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The prior art does not disclose or suggest exposing the image of the at least one diffraction grating pattern and an image of the reference pattern onto the substrate simultaneously, the at least one diffraction grating pattern and the reference pattern comprising a test mark in the evaluation mask; and measuring a relative distance of the image of the at least one diffraction grating pattern formed on the substrate and the image of the reference image formed on the substrate in combination with all the other steps recited in independent claim 35

The prior art does not disclose or suggest exposing the image of the at least one diffraction grating pattern and an image of the reference pattern onto the substrate simultaneously, the at least one diffraction grating pattern and the reference pattern comprising a test mark in the evaluation mask under the condition of $\frac{\lambda}{NA(1-\sigma)} < P < 2 < \lambda/\{NA(1+\sigma)\}, \text{ where } \sigma \text{ is a partial coherence of a lighting }$ optical system for lighting the rest mark, P is a period of an image of a first pattern of the test mark, λ is the wavelength of light of the lighting optical system and NA is a numerical aperture of the projection optical system; and measuring the relative distance of the image of the at least one diffraction grating pattern formed on the substrate and the image of the reference image formed on the substrate in combination with all the other elements recited in independent claim 42.

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to Alan A. Mathews whose telephone number is (571) 272-2123. The examiner can normally be reached on Monday through Friday from 8:00 AM to 4:30 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Judy Nguyen can be reached on (571) 272-2258. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Alan A. Mathews Primary Examiner

Celan Walken

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